

SEMI G30-88

TEST METHOD FOR JUNCTION-TO-CASE THERMAL RESISTANCE MEASUREMENTS OF CERAMIC PACKAGES

1 Purpose

The purpose of this test is to determine the thermal resistance of ceramic packages using thermal test chips. This test method deals only with junction-to-case or mounting surface measurements of thermal resistance and limits itself to heat sink and fluid bath testing environments. Following the guidelines outlined in this test method, junction-to-case thermal resistance measurements of ceramic packages using the heat sink and fluid bath methods should give the same results only under certain limited conditions (i.e., under conditions that approximate unidirectional heat flow through the chip and substrate to the preferred heat removal surface). If discrepancies occur, the heat sink mounting technique shall be considered as the referee test method. The heat sink mounting method for measuring junction-to-case thermal resistance will be a conservative measure of the package's ability to transfer heat to the ambient environment because heat sinking is provided only on one side of the package, whereas the fluid bath mounting method has the potential for equally cooling both sides of the package.

1.1 *Definitions* — The following definitions and symbols shall apply for the purpose of this test:

- a. *case temperature*, T_C , in degrees Celsius. The case temperature is the temperature at a specified accessible reference point on the package in which the microelectronic chip is mounted.
- b. *mounting surface temperature*, T_M , in degrees Celsius. The mounting surface temperature is the temperature of a specified point at the device-heat sink mounting interface (or primary heat removal surface).
- c. *junction temperature*, T_J , in degrees Celsius. The term is used to denote the temperature of the semiconductor junction in the microcircuit in which the major part of the heat is generated. For purposes of this test, the measured junction temperature is only indicative of the temperature in the immediate vicinity of the element used to sense the temperature.
- d. *power dissipation*, P_H , in watts, is the heating power applied to the device causing a junction-to-reference point temperature difference.
- e. *thermal resistance, junction-to-specified reference point*, $R_{\theta JR}$, in degrees Celsius/watt. The thermal resistance of the microcircuit is the temperature difference from the junction to some reference point on the package divided by the power dissipation P_H .
- f. *temperature-sensitive parameter*, TSP, is the temperature-dependent electrical characteristic of the junction under test which can be calibrated with respect to temperature and subsequently used to detect the junction temperature of interest.

2 Apparatus

2.1 The apparatus required for these tests shall include the following as applicable to the specified test procedures.

- a. Thermocouple material shall be copper-constantan (type T) or equivalent, for the temperature range -100 to +300°C. The wire size shall be no larger than AWG size 30. The junction of the thermocouple shall be welded to form a bead rather than soldered or twisted. The accuracy of the thermocouple and associated measuring system shall be $\pm 0.5^\circ\text{C}$.
- b. Suitable electrical equipment as required to provide controlled levels of conditioning power and to make the specified measurements. The instrument used to electrically measure the temperature-sensitive parameter shall be capable of resolving a voltage change of 0.5 mV.
- c. Controlled temperature chamber, fluid bath, or heat sink capable of maintaining the specified reference point temperature to within $\pm 0.5^\circ\text{C}$ of the preset (measured) value. Typical temperature-controlled heat sink and fluid bath assemblies are presented for illustrative purposes only.

2.2 *Heat Sink Assembly* — A typical heat sink assembly for mounting the microelectronic device under test is shown in Figure 1. The primary heat sink is water cooled using a temperature-controlled fluid circulator bath. An adapter socket/heat sink is fastened to the heat removal surface of the primary heat sink, and has a special geometry to handle specific size packages (e.g., flat packs, dual-in-line packages, chip carriers). This adapter provides a repeatable and

efficient interface between the package and the primary heat sink. The mounting surface temperature is determined with a thermocouple attached from the side or bottom of the adapter with a thermal conducting adhesive or grease at or near the interface between the adapter and the package. It is at this point that the device-under-test temperature is specified and controlled. The adapter also contains the socket or other electrical interconnection scheme. A thin coating (about 25 – 50 mm thick) of a thermal heat-sinking compound, such as zinc-oxide-loaded silicone thermal grease, is used at the interface to provide a reliable thermal contact.

2.3 Fluid Bath Assembly — A typical temperature-controlled fluid bath for thermally characterizing the microelectronic device under test is shown in Figure 2. In this figure, the package is mounted in a fluid bath separate from the fluid circulator, although it can be immersed directly in an integrated fluid circulator/bath unit. The fluid in the bath should be continuously stirred or agitated to ensure the required temperature stability. Since this working fluid is being used as an infinite heat sink, the case-to-fluid (ambient) temperature difference at the case temperature reference point of interest should be minimized, i.e., less than or equal to 20°C. For case-to-fluid temperature differences greater than 20°C, accuracy and repeatability difficulties may occur due to a large variable temperature gradient in the fluid film boundary layer at the package-fluid interface. The case-to-fluid temperature difference can be minimized by increasing the fluid velocity and by decreasing the power density seen by the fluid. The device under test should be mounted such that heat transfer to the fluid is not impeded. For leaded devices, the leads should be oriented in such a manner so as not to interfere with the heat transfer to the fluid and provide freedom to any thermal currents caused by the power dissipation within the package. The case temperature of the device under test should be measured with a thermocouple that is attached to the package and should not be assumed to be at the fluid temperature. Care should be taken to minimize exposure of the thermocouple bead to the high temperature gradient in the fluid film boundary layer at the package-fluid interface. The working fluid should have a thermal conductivity at 25°C of at least 0.0006 W/cm°C. Working fluids such as inert fluorocarbon liquids and silicone oils are suitable as a cooling media.

3 Procedure

3.1 Direct Measurement of Reference Point Temperature — T_C . For the purpose of measuring a microelectronic device thermal resistance, the reference point temperature shall be measured at the package

location of highest temperature which is accessible outside the package. This reference point location is determined with the device operating in free air and with no external heat-sinking. In general, this reference point is found to be on the outside surface of the package substrate directly underneath the chip in the major path of heat flow from the chip to the heat sink or ambient. Examples of the reference point location for both cavity-up and cavity-down ceramic packages are depicted in Figure 3. The package surface may be altered to facilitate this measurement, provided that such alteration does not affect the original heat transfer paths and, hence, the thermal resistance, within the package by more than a few percent. For packages with an integral heat dissipater attached to the outside surface of the package substrate, the case temperature reference point shall be on the surface of the heat dissipater at a point opposite the backside of the chip as indicated in Figure 4.

3.1.1 Case temperature, T_C . The microelectronic device under test shall be mounted under specified conditions so that the case temperature can be held at the specified value. A thermocouple shall be attached on the surface of the device package directly under the chip. A conducting epoxy may be used for this purpose. The thermocouple bead should be in direct mechanical contact with the case of the microelectronic device under test. For devices which, in their normal application, are intimately connected (by pressure contact, adhesive, soldering, or other means) to an external heat sink, the mounting surface temperature, as measured directly below the primary heat removal surface of the case, may be used as the equivalent case temperature.

If it is found that attaching the thermocouple directly to the case is impractical, an alternate approach utilizing a thermocouple welded to one side of a thin metal disk should be used. This can be accomplished by parallel gap welding the crossed thermocouple wires to one side of a 0.25 cm (0.094 in) diameter, 0.02 cm (0.008 in) thick beryllium-copper disk and then, with a thin layer of adhesive, bonding the other side of the disk to the case at the point of interest.

3.1.1.1 Mounting surface temperature, T_M . The mounting surface temperature is measured directly below the primary heat removal surface of the case. It is measured with a thermocouple at or near the mounting surface of the heat sink. A typical mounting arrangement is shown in Figure 5. The surface of the copper mounting base shall be nickel plated and free of oxides.

The thermocouple hole shall be drilled into the mounting base such that the thermocouple lead is directly below the area on the case of interest. It is